

Status of Photo-Detector Developments Based on STJs for COBAND Project

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For COBAND collaboration

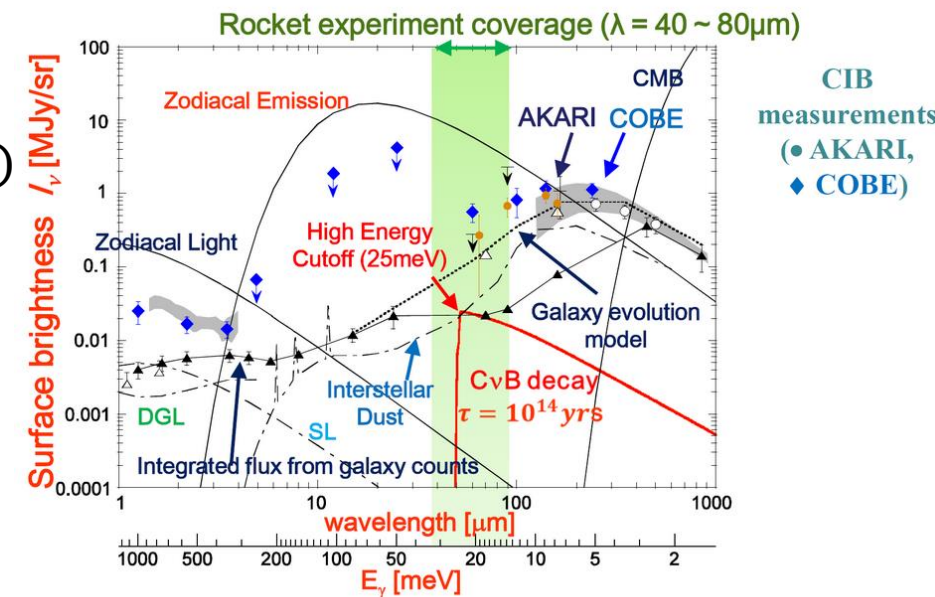


Introduction

- We are developing STJ detectors and cryogenic amplifiers for COBAND (COsmic BAcKground Neutrino Decay search) experiment.
- Brief introduction of COBAND experiment
 - measure the neutrino mass by observing the neutrino decay of cosmic background neutrino.
 - COBAND experiment consists of two type of measurement: rocket experiment and satellite experiment
- Requirements for the detector
 - Continuous spectrum of photon energy around $E=25 \text{ meV}$ ($\lambda=50 \mu\text{m}$)
 - Energy measurement for a single photon with a better than 2% resolution for $E=25 \text{ meV}$ to identify the sharp edge in the spectrum



STJ can achieves requirements.
Nb/Al-STJ for the rocket experiment.
Hf-STJ for the satellite experiment.



Source : S. Matsuura Astrophys. J. 737 (2011) 2

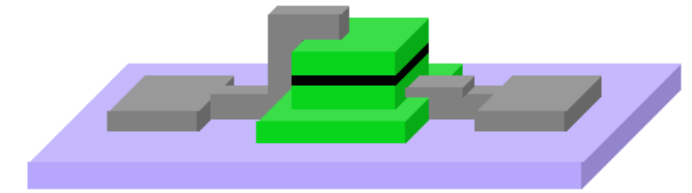
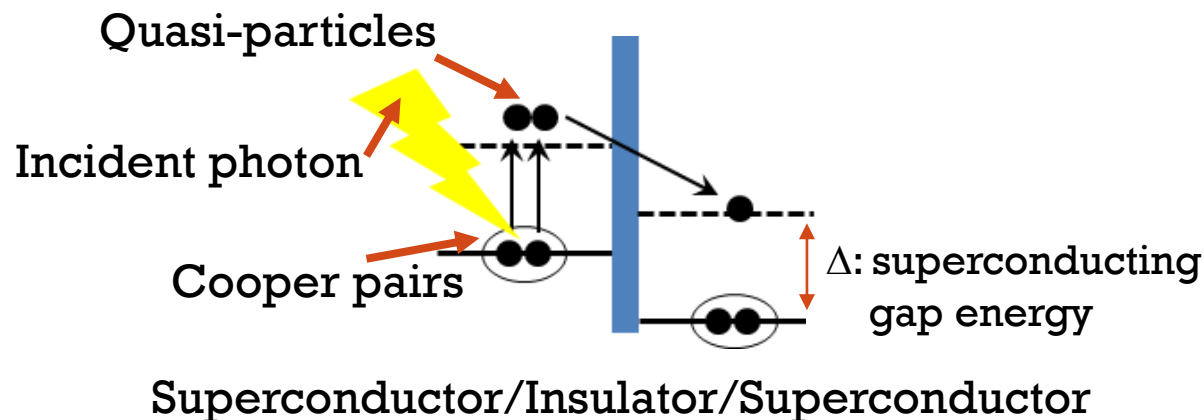
STJ (Superconducting Tunnel Junction) Detector

Structure

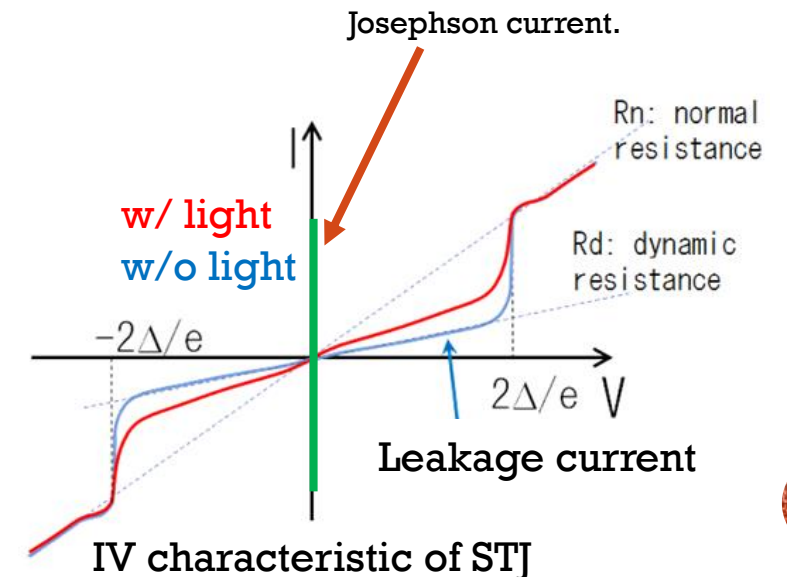
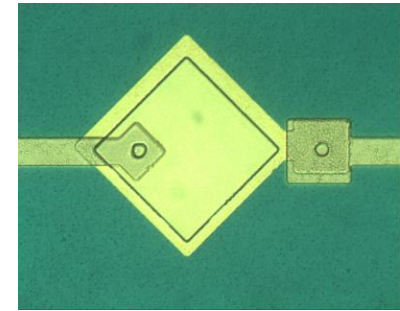
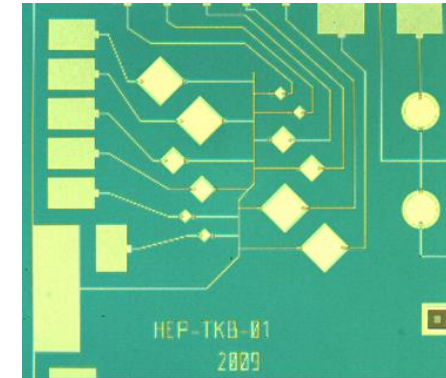
- Superconductor/Insulator/Superconductor
- Size: dozens ~ hundreds μm square and 500 nm height

Working principle

- Incident photon is absorbed in the superconductor and excites cooper pairs.
- Excited cooper pairs become quasi-particles.
- Quasi-particles go through insulator by tunnel effect.
- Number of quasi-particles is determined by energy of incident particle.
- Thus, we can measure the energy of incident particle by measuring the tunnel current.



Overhead view of STJ detector



Energy resolution of STJ detector

- Statistical fluctuation in number of quasi-particles determines STJ energy resolution.
- Smaller superconducting gap energy Δ yields better energy resolution.

$$\sigma_E = \sqrt{(1.7\Delta)F\varepsilon}$$

Material	T _c (K)	Δ (meV)
Si	-	1200
Niobium	9.20	1.550
Aluminum	1.14	0.172
Hafnium	0.16	0.021

Δ : Superconducting gap energy
 F: fano factor
 ε : Photon energy

T_c : Superconducting critical temperature
 Need $\sim 1/10T_c$ for practical operation

Nb

- Well established as Nb/Al-STJ
- $N_{q.p.} = 25\text{meV}/1.7\Delta = 9.5$
- poor resolution but counting is possible

Hf

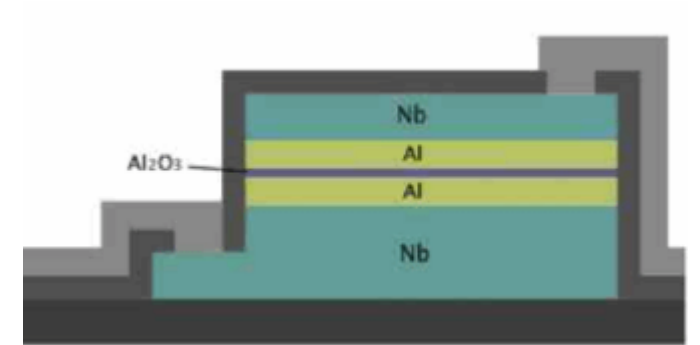
- Hf-STJ as a photon detector is not established
- $N_{q.p.} = 25\text{meV}/1.7\Delta = 735$
- 2% energy resolution is achievable if fano factor < 0.3

Development of Nb/Al-STJ

Performance of our Nb/Al-STJ sample

Our Nb/Al-STJ is fabricated with CRAVITY at AIST

Structure: Nb/Al/AlO_x/Al/Nb = 100nm/70nm/1nm/70nm/200nm



▪ Leakage current

▪ Requirement: $I_{\text{leak}} < 100\text{pA}$ to detect a single far-infrared photon ($\lambda=40\text{-}80\mu\text{m}$)

▪ Measured:

STJ size	# of samples	$I_{\text{leak}}@0.3\text{mV}$
$20 \times 20 \mu\text{m}^2$	7	$39 \pm 13 \text{pA}$
$10 \times 10 \mu\text{m}^2$	20	$14 \pm 7 \text{pA}$

Nb/Al-STJ meets the requirements of the rocket experiment !

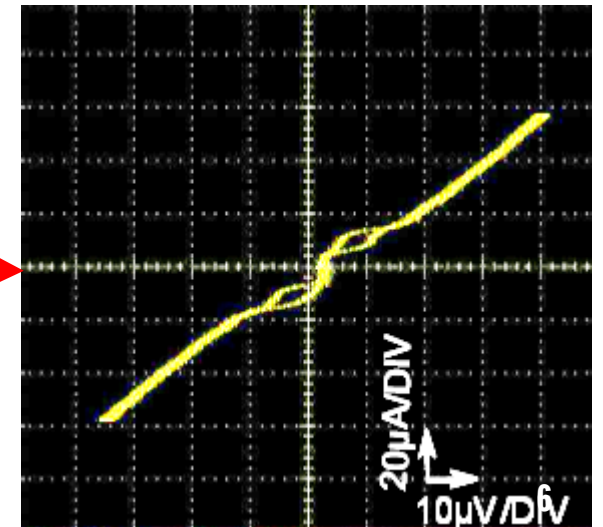
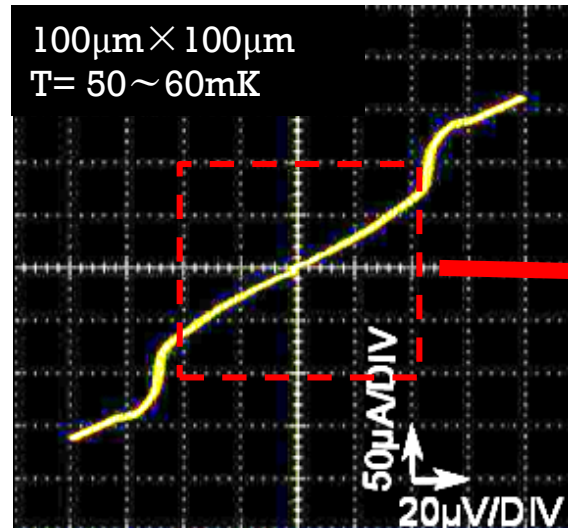
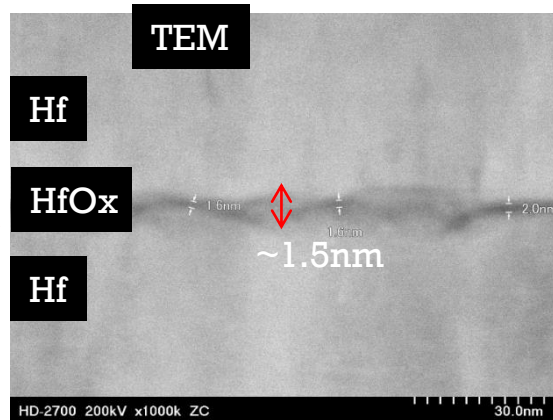
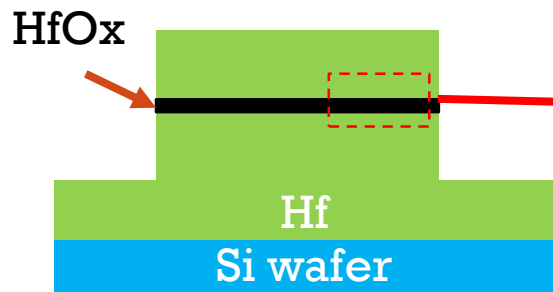
Development of Hf-STJ

- Earlier version of our Hf-STJ
 - Structure: Hf/HfO_x/Hf = 250nm/1.5nm/300nm
 - $\Delta \sim 20\mu\text{eV}$
 - Leakage current at $20\mu\text{V} = 20\mu\text{A}@50\text{mK}$ (100 μm sq. sample)

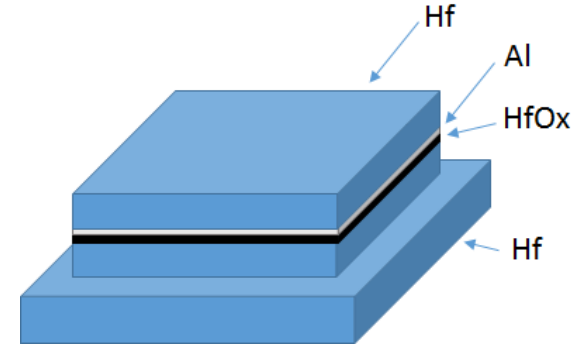
Leakage current is too large.

Required leakage current = $10\text{pA}@50\text{mK}$

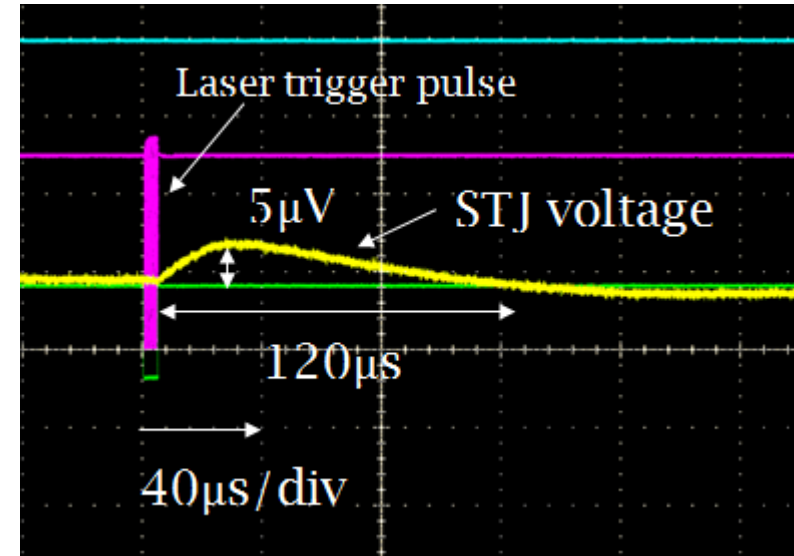
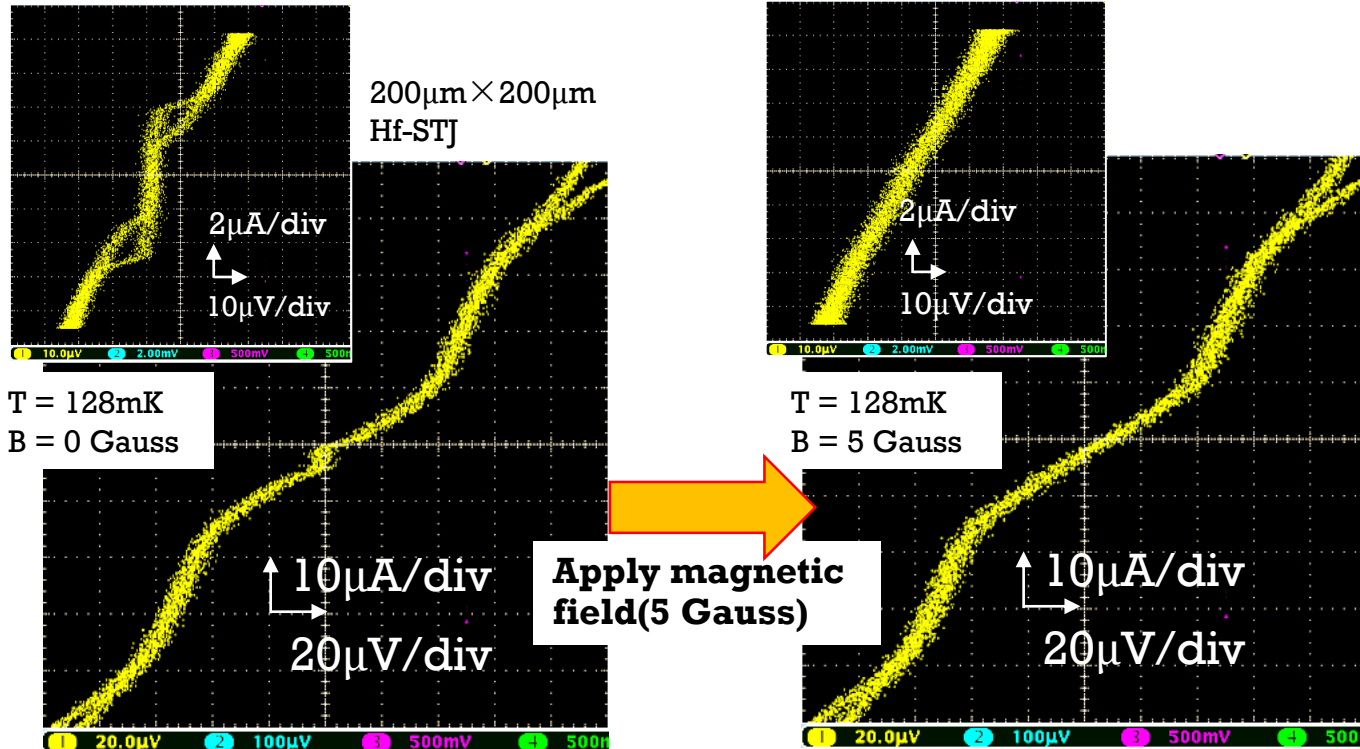
Necessary to perform improvements very much.



Development of Hf-STJ (Hf-STJ w/ thin Al layer)



- We add thin (a few nm) Al layer between the insulator and the upper Hf layer.
 - Josephson current is observed and it's suppressed by magnetic field.
 - $\Delta = 20\sim 30\mu\text{eV}$.
 - $I_{\text{leak}} = 5\mu\text{A}@128\text{mK}$ ($200\mu\text{m} \times 200\mu\text{m}$ sample)
 - I_{leak} becomes 16 times smaller than old sample.
- **Response to visible laser pulses is observed.**



Response to laser pulses

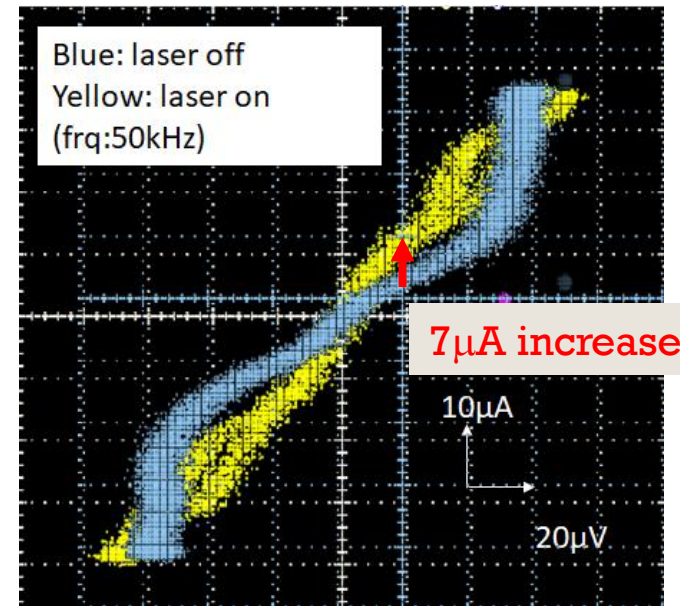
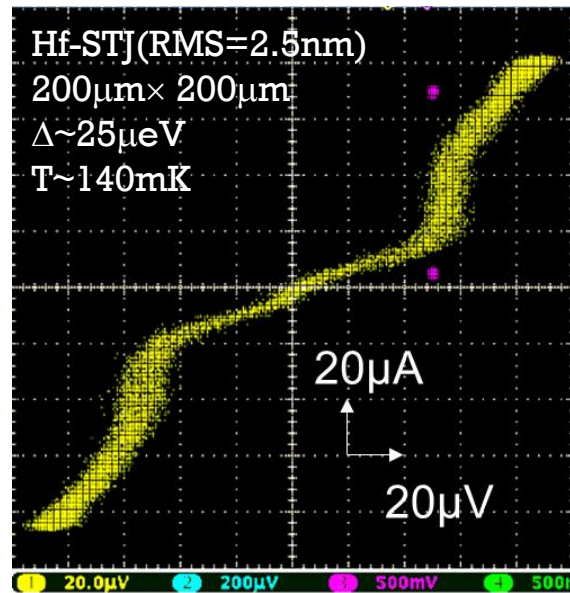
- $\lambda = 465\text{nm}$
- 5MHz oscillation 5 μs per 100ms.

Development of Hf-STJ (pure Hf-STJ)

- To reduce leakage current, We modified the sputtering condition to make smooth Hf layers.
 - Rough surfaces of Hf layer cause defects of insulator.
- We made a Hf-STJ consisting of Hf layers with a small roughness of 2.5 nm RMS deposited a new sputtering condition.

Result (200 μ m sq. sample):

- Leakage current: 6 μ A , 16 times smaller than the old Hf-STJ.
- Response to laser continuous illumination is observed.



Response to visible($\lambda=465$ nm) DC-like laser light
T = 140mK, 9Gauss B field is applied.

This Hf-STJ works as a STJ photon detector.

However, leakage current is still large, need more improvement.

Development of cold amplifier

- Our Nb/Al-STJ achieves the requirement.
- But, we haven't succeeded in detecting a far infrared single photon due to readout noise.
- To improve the signal-to-noise ratio, we are developing cold amplifier.

- Requirements for cold amplifier

- **Operation at cryogenic temperature**

- To reduce STJ's thermal noise ($\propto \sqrt{T} e^{-\Delta/kbT}$), we need to make cooler 300mK.
 - Cold amplifier should be able to operate at 300mK.

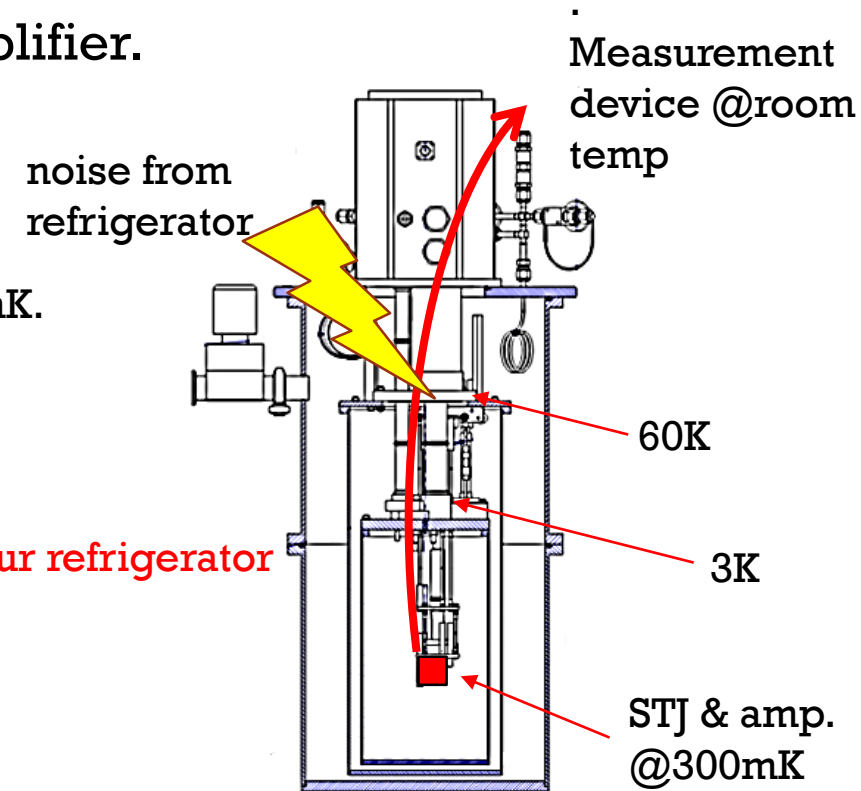
- **Low power consumption**

- Typical cooling power of our refrigerator is $100\mu\text{W}@300\text{mK}$.
 - Power consumption of the amplifier should be less than cooling power of our refrigerator

- **Response speed**

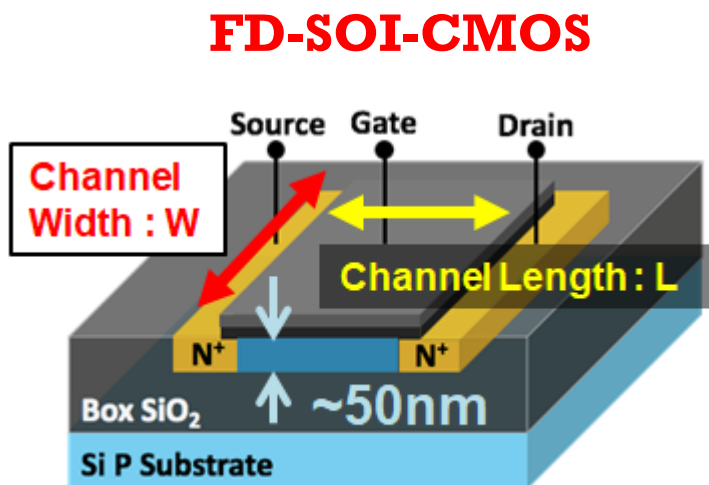
- The integration time of charge of Nb/Al-STJ is a few μs .
 - Amplification gain should be large enough up to 1MHz.

→ Cold amplifier using **SOI(Silicon-On-Insulator)** technology can achieve these requirements

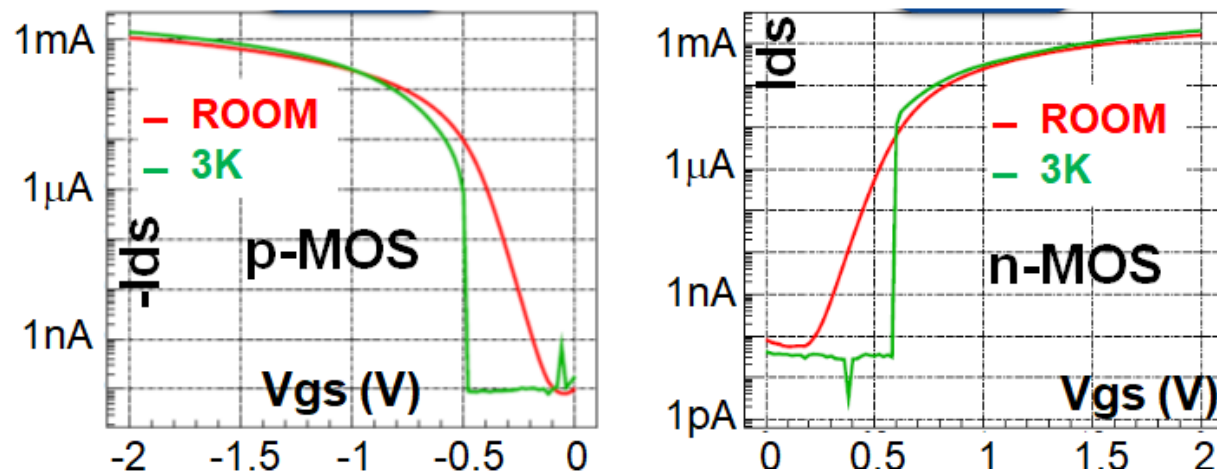


SOI (Silicon-On-Insulator) device

- SOI device consists of devices on silicon thin film that exists on insulating film.
 - FD(Fully depleted) SOI: thin SOI layer(normally<50nm). All body areas under the channel are depleted.
- FD-SOI device was proved to operate at 4.2K by a JAXA group.
- Characteristics:
 - Low power consumption
 - High speed
 - Easy large scale integration
 - Suppression of charge-up by high mobility carrier due to thin depletion layer(~50nm)



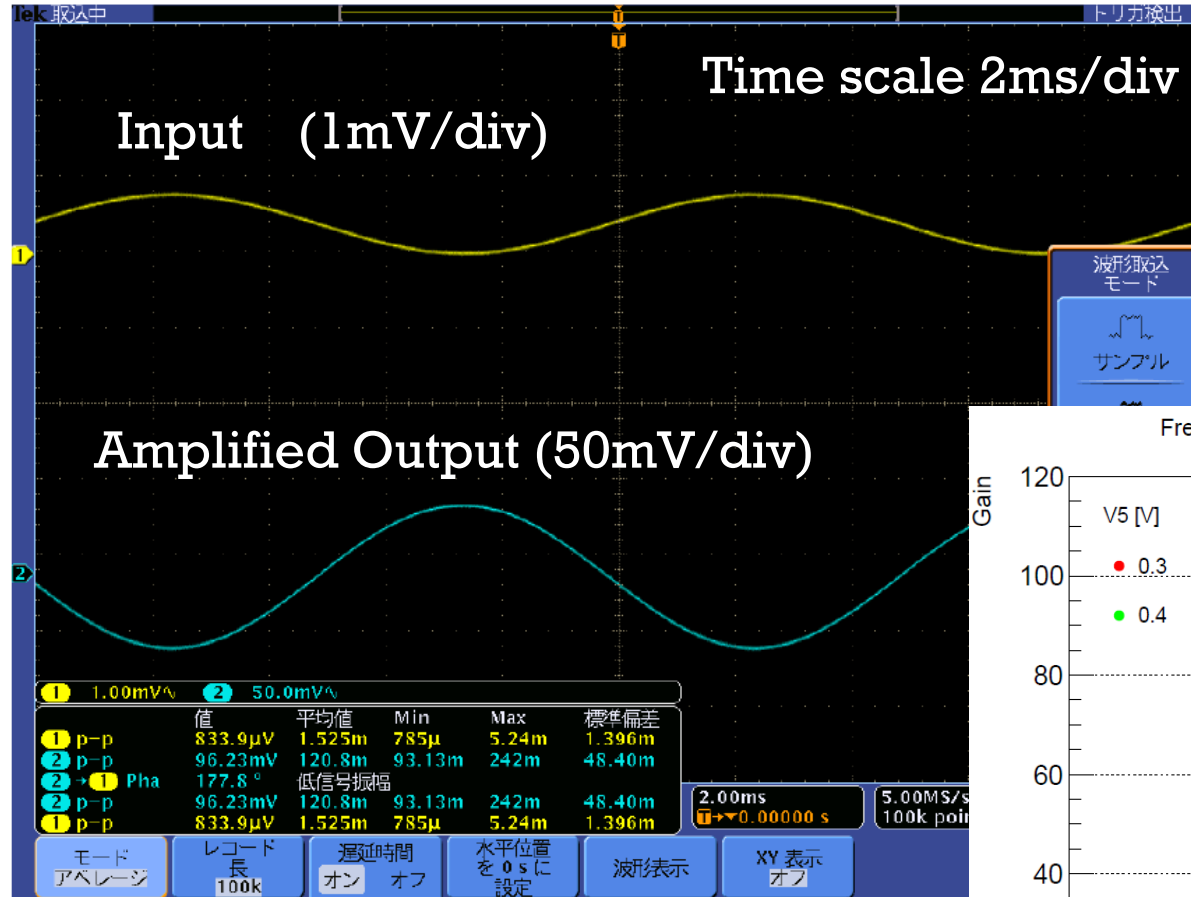
I_d - V_g curve of $W/L=10\mu\text{m}/0.4\mu\text{m}$ at $|V_{ds}|=1.8\text{V}$



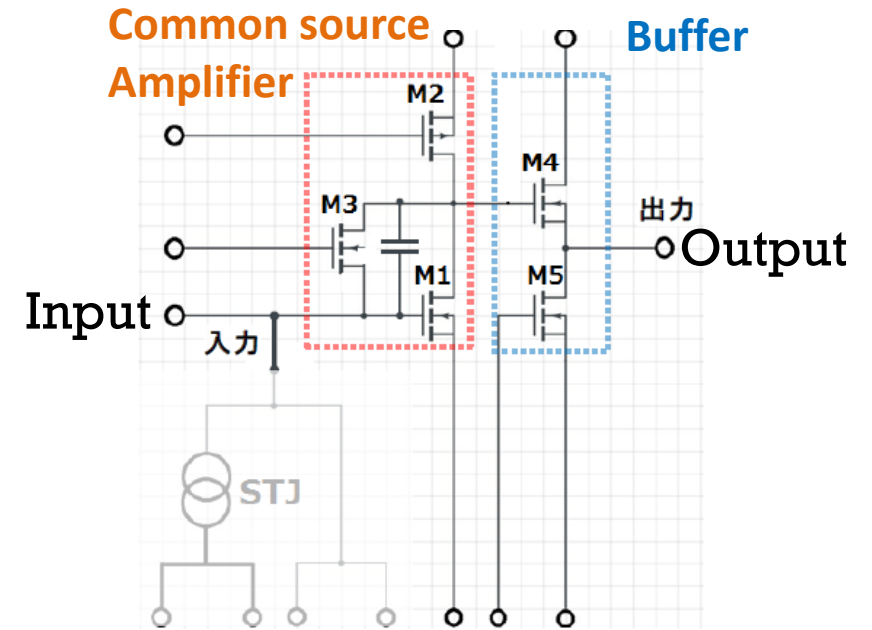
Both p-MOS and n-MOS show excellent performance at 3K and below.

SOI-pre-amplifier 4th prototype

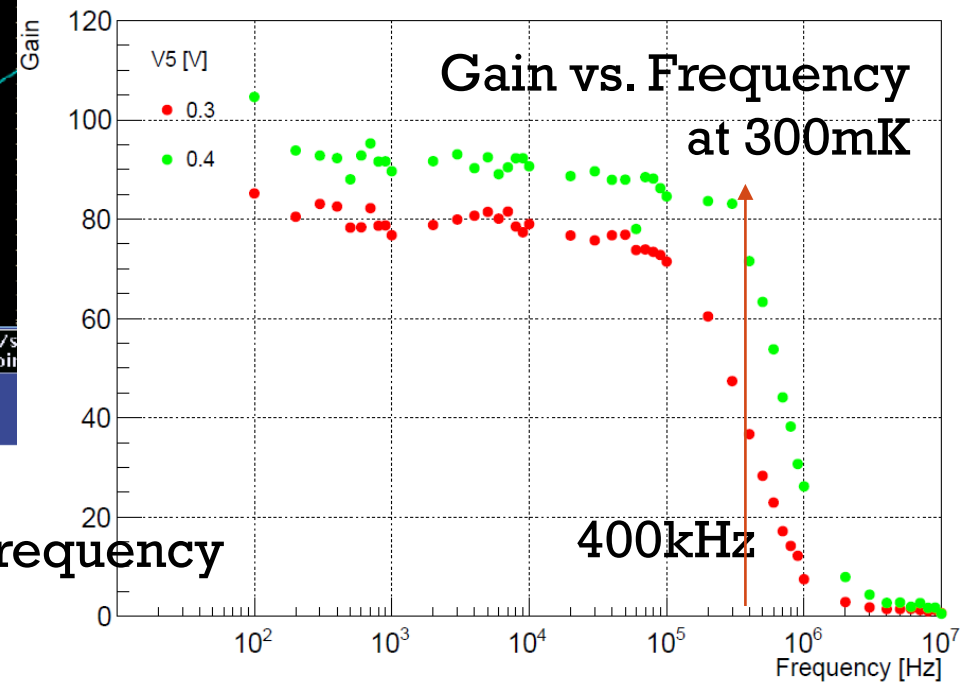
Input and Amplified Output



Circuit design



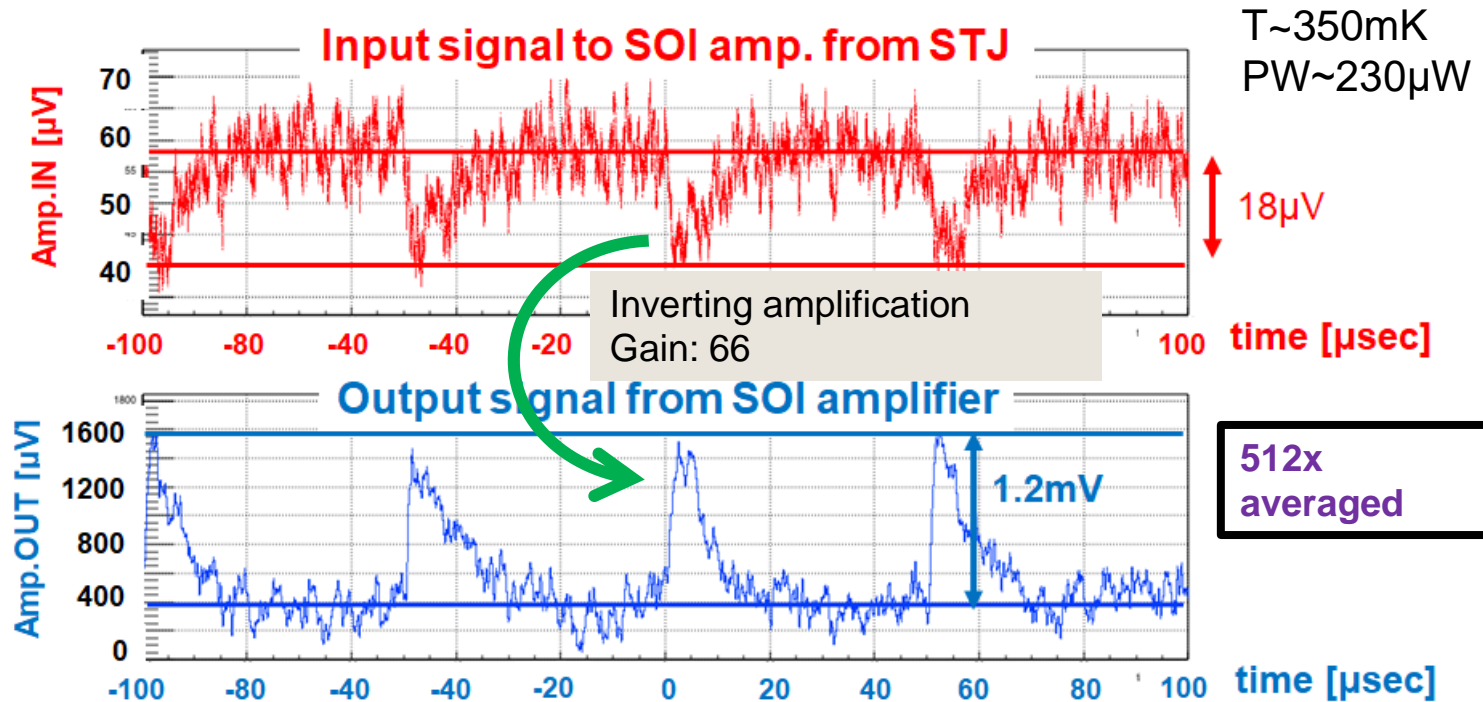
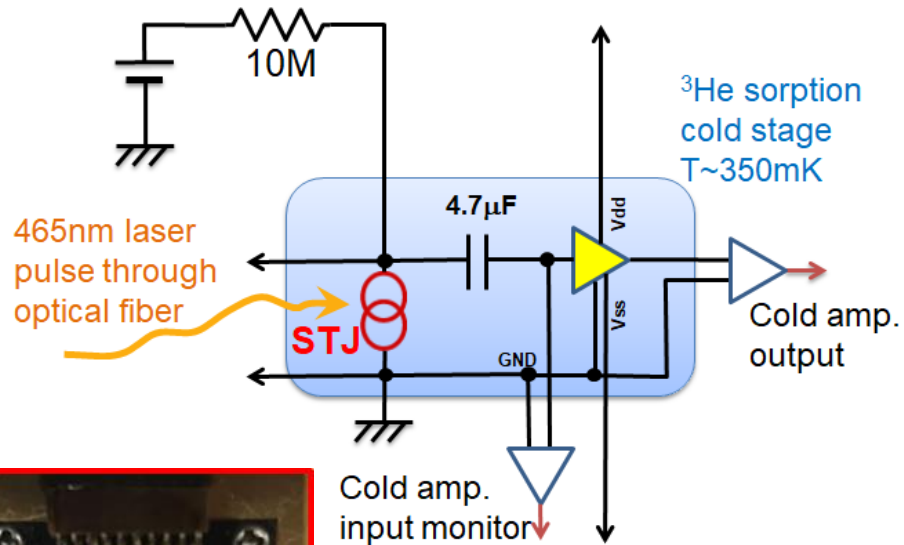
Frequency characteristic of cold amplifier(SOISTJ4) at 300mK



Gain of 80 was achieved for a signal frequency up to 400kHz signals at 300mK.

STJ response to laser pulse amplified by Cold amplifier

- We connect 20 μm sq. Nb/Al-STJ and SOI amplifier on the cold stage through a capacitance



We observe 20 μm sq. Nb/Al-STJ responses to laser pulses of $\lambda=465\text{nm}$ amplified by SOI amplifier situated at T=350mK

Summary

- R&D of STJ detectors and SOI-cryogenic amplifier are underway.
- Nb/Al-STJ satisfied our requirement for leakage current less than 0.1 nA
- Leakage current of Hf-STJ becomes 1/16 by using smooth Hf layer
- Cryogenic amplifier with the SOI technology worked at 300mK
- **We have succeeded in amplifying the STJ signal with the SOI cryogenic amplifier.**